

DOCKET NO: 288992US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
YASUO MATSUKI, ET AL. : ATTN: APPLICATION DIVISION
SERIAL NO: NEW U.S. PCT APPLICATION :
(BASED ON PCT/JP04/15101)
FILED: HEREWITH :
FOR: COMPOSITION FOR FORMING :
SILICON-COBALT FILM, SILICON-
COBALT FILM AND METHOD FOR
FORMING SAME

PRELIMINARY AMENDMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Prior to examination on the merits, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.